

## Fabrication and Characterization of Mo-SiO<sub>2</sub> Composite

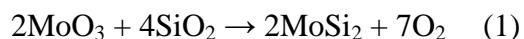
H. Razavi, K. Yamada, T. Katayama, N. Saito, K. Nakashima, K. Kaneko

Dept. of Material Science and Engineering, Kyushu University, Fukuoka, 819-0395, Japan

**1. Introduction** Functionally graded materials (FGM) are composite materials where the material composition and/or microstructure vary gradually to achieve enhanced physical properties with respect to the spatial coordinates [1]. Umemoto et al. fabricated Mo-SiO<sub>2</sub> FGM by the slip-casting method and proposed a new class of hermetically sealed HiDLs by using this Mo-SiO<sub>2</sub> FGM [2]. In general, metallic Mo and SiO<sub>2</sub> glass have a low wettability because of adhesive forces between a metal and glass; however their composite materials can be fabricated to form FGM. In this work, the interfaces between Mo and SiO<sub>2</sub> were mixed and sintered at different temperatures, then their interfaces were studied in detail by XRD and TEM.

**2. Experiment** Mo powder (average size: 1.5 μm) and SiO<sub>2</sub> powder (average size: 1.4 μm) were used as starting materials. A part of this Mo powder (as-received Mo) was rinsed with hydrochloric acid (treated Mo). The mixture of Mo-SiO<sub>2</sub> water suspension was prepared under ultrasonic stirring. Combined sedimentation and pressurized slip-casting method were carried out, and then the slurry was cast in plastic molds on a porous ceramic block. After being dried at room temperature in vacuum for 24 h, samples 1, 2, 3 and 4 were sintered in vacuum at 1200 °C for 0 h, 1200 °C for 5 h, 1300 °C for 0 h and 1735 °C for 0 h, respectively. Further, the microstructure of each sample was observed by Co K<sub>α</sub> radiation XRD (at 40 kV and 40 mA) and TEM (JEOL JEM-3200FSK electron microscope operating at 300 kV).

**3. Results and discussion** Fig. 1.a shows the XRD pattern of as-received Mo-SiO<sub>2</sub> containing Mo and MoO<sub>3</sub> peaks. This suggests before sintering, MoO<sub>3</sub> layers exist on the surface of Mo particles (see also Fig.1.b). According to XRD results obtained from as-received Mo-SiO<sub>2</sub> at higher temperatures, MoO<sub>3</sub> peaks gradually distinguished. Meanwhile, MoSi<sub>2</sub> peaks started to appear due to a possible chemical reaction between Mo and SiO<sub>2</sub> (Equation 1). Contrary to as-received Mo, treated Mo XRD results showed Mo peaks without any other peaks (Fig. 2.a).



In order to confirm this chemical reaction in the composites, we also performed

transmission electron microscopy (TEM). Fig. 2.b represents HR-TEM image and FFT pattern of MoSi<sub>2</sub> observed in <111> direction which confirms the presence of MoSi<sub>2</sub>.

References

- [1] Y. Miyamoto, W.A. Kaisser, B.H. Rabin, A. Kawasaki and R.G. Ford, *Functionally graded materials: design, processing and applications, Mater technol series*, Kluwer Academic Publisher (1999).
- [2] Umemoto, A., Hayashi, K., Hayano, K., Saito, N., Kaneko, K., Nakashima, K., *Ceramic Transactions* 198 (2007), pp. 219-224.

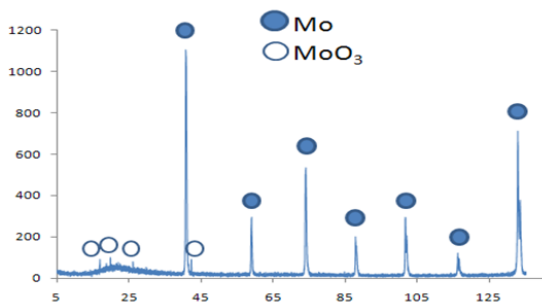


Fig.1.a .XRD pattern of as-received Mo-SiO<sub>2</sub> containing Mo and MoO<sub>3</sub> peaks at 1200 °C for 0 h.

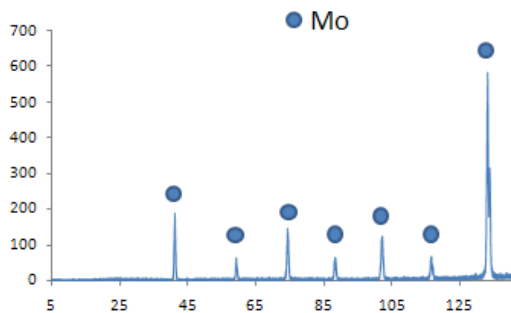


Fig. 2.a. XRD pattern of treated Mo-SiO<sub>2</sub> containing Mo peaks at 1200 °C for 0 h without any other peaks.

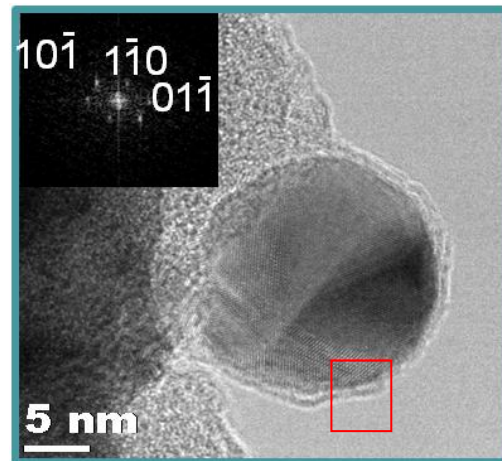


Fig. 1.b. HR-TEM and FFT pattern of as-received Mo in sintering temperature of 1200 °C for 0 h show MoO<sub>3</sub> on the surface of Mo.

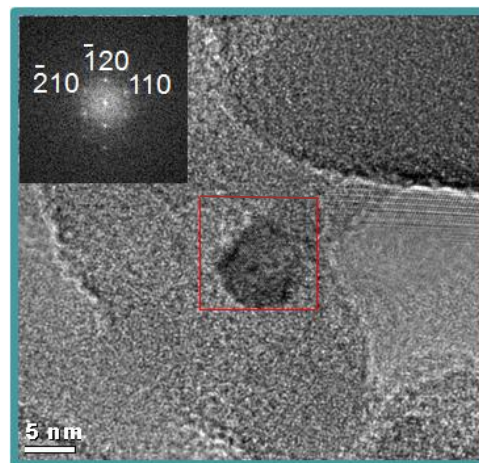


Fig. 2.b. HR-TEM image and FFT pattern of MoSi<sub>2</sub> observed in <111> direction.